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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/736,020	12/15/2003	Guo Liu	SMBZ 2 01016 6865-312	4169
James W. McKee Fay, Sharpe, Fagan Minnich & McKee, LLP, 7th Floor 1100 Superior Avenue			EXAMINER	
			THOMPSON, CAMIE S	
			ART UNIT	PAPER NUMBER
Cleveland, OH 44114-2518			1794	
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			02/19/2008	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Application No. Applicant(s) 10/736.020 LIU. GUO Office Action Summary Examiner Art Unit Camie S. Thompson 1794 -- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --Period for Reply A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS. WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). Status 1) Responsive to communication(s) filed on Amendment filed December 3, 2007. 2a) This action is FINAL. 2b) This action is non-final. 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213. Disposition of Claims 4) Claim(s) 1-13 and 17-32 is/are pending in the application. 4a) Of the above claim(s) _____ is/are withdrawn from consideration. 5) Claim(s) 1-13, 17-19, 23-32 is/are allowed. 6) Claim(s) 20 and 22 is/are rejected. 7) Claim(s) 21 is/are objected to. 8) Claim(s) _____ are subject to restriction and/or election requirement. Application Papers 9) The specification is objected to by the Examiner. 10) The drawing(s) filed on is/are; a) accepted or b) objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abevance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152. Priority under 35 U.S.C. § 119 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. Attachment(s)

1) Notice of References Cited (PTO-892)

Notice of Draftsperson's Patent Drawing Review (PTO-948)

Information Disclosure Statement(s) (PTO/SB/08)
 Paper No(s)/Mail Date ______.

Interview Summary (PTO-413)
 Paper No(s)/Mail Date.

6) Other:

5) Notice of Informal Patent Application

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DETAILED ACTION

 Applicant's amendment and accompanying remarks filed December 3, 2007 are acknowledged.

Examiner acknowledges amended claim 1.

 The rejection of claims 1-2, 4-7, 9, 12-13, 20 and 22 under 35 U.S.C. 102(b) as being anticipated by Velthaus et al., U.S. Patent Number 5,505,986 is overcome by applicant's amendment.

Claim Rejections - 35 USC § 102

4. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- Claims 20 and 22 are rejected under 35 U.S.C. 102(b) as being anticipated by Velthaus et al., U.S. Patent Number 5.505.986.

Velthaus discloses a phosphor layer with the formula M"M"'2X4:RE where M' is magnesium, calcium, strontium or barium; M"' is sulfur or selenium and RE is a rare earth activator (see abstract and column 1, line 60-column 2, line 8). It is disclosed in column 2, lines 38-60 that a suitable insulating dielectric layer is deposited on the top and bottom of the phosphor layer. Additionally, Velthaus discloses that insulators such as AlN can be used as barriers layers. Velthaus also discloses that the rare earth activator can be europium or cerium (see column 2, line 68).

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6. Claim 21 is objected to as being dependent upon a rejected base claim, but would be

allowable if rewritten in independent form including all of the limitations of the base claim and

any intervening claims. The prior art does not provide for the recited phosphor laminate, further

including the aluminum nitride barrier layer having a thickness of about 30 nm to about 50 nm.

7. Claims 1-13, 17-19, and 23-32 are allowed. The prior art does not provide for the recited

improved phosphor film with an aluminum nitride barrier layer having a thickness of about 30

nm to about 50 nm when the aluminum nitride barrier is used in conjunction with a rare earth

activated alkaline earth phosphor. The prior art does not provide for a thick film dielectric

electroluminescent device constructed on a glass or glass ceramic substrate and comprising a

phosphor selected from the group consisting of

a) a rare earth activated barium thioaluminate;

(b) a rare earth activated fine grained zinc sulfide;

(d) a rare earth or transition metal activated zinc selenide; and

(e) a rare earth or transition metal activated zinc sulfo-selenide,

wherein said phosphor film of (a), (b), (d) and (e) is provided with an aluminum

nitride barrier layer on a top and/or bottom side of the phosphor film, said aluminum

nitride barrier layer improving the stability of the interface between the phosphor film

and the display.

The prior art does not provide for a method for making a stabilized phosphor laminate for use in

a thick film dielectric electroluminescent device, said method comprising:

i) deposition of a phosphor selected from the group consisting of

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a) a rare earth activated barium thioaluminate;

- (b) a rare earth activated fine grained zinc sulfide;
- (d) a rare earth or transition metal activated zinc selenide; and
- (e) a rare earth or transition metal activated zinc sulfo-selenide,

onto a glass or glass ceramic substrate incorporating a first set of address lines and a dielectric laver:

- ii) deposition of a layer of aluminum nitride on top of said phosphor film of (a)-(b) and
- (d)-(e); and
- iii) annealing said phosphor film at a temperature of up to about 1100°C.

Response to Arguments

8. Applicant's arguments filed December 3, 2007 have been fully considered but they are not persuasive. Applicant has amended claim 1 to distinguish over the prior art. However, present claims 20 and 22 are not distinguishable over the prior art. Present claim 20 recites a phosphor laminate comprising a rare earth activated alkaline earth thioaluminate and an aluminum nitride layer provided directly adjacent a top of the phosphor layer. Velthaus discloses a rare earth activated alkaline earth thioaluminate phosphor with an aluminum nitride barrier layer on top of the phosphor layer. The rejection is maintained.

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE

MONTHS from the mailing date of this action. In the event a first reply is filed within TWO

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date of this final action.

MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing

Any inquiry concerning this communication or earlier communication from the examiner should be directed to Camie S. Thompson whose telephone number is (571) 272-1530. The examiner can normally be reached on Monday through Friday from 7:30 am to 4:00 pm. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Terrel Morris, can be reached at (571) 272-1478. The fax phone number for the Group is 571-273-8300

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

/Terrel Morris/ Terrel Morris Supervisory Patent Examiner

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